

FORM PTO-1449 U.S. DEPARTMENT OF COMMERCE (Rev. 2-32) PATENT AND TRADEMARK OFFICE	ATTY. DOCKET NO. KPG-5045US	SERIAL NO 10/044,261
	APPLICANT Kitson	
	FILING DATE January 10, 2002	GROUP 2854

Information Disclosure  
Statement by Applicant

(Use several sheets if necessary)



## U.S. PATENT DOCUMENTS

Exmr Initial	Document Number	Date	Name	Class	Sub Class	Filing Date
JSC	4,532,005	7/1985	Grieco et al.	216	47	
	4,708,925	11/1987	Newman	430	270	
	5,563,011	10/1996	Shipley	430	7	
	5,609,995	3/1997	Akram et al.	430	327	
	6,294,311 B1	9/2001	Shimazu et al.	430	271.1	
	6,352,811 B1	3/2002	Patel et al.	430	270.1	
	6,352,812 B1	3/2002	Shimazu et al.	430	273.1	
	6,358,669 B1	3/2002	Savariar-Hauck et al.	430	273.1	

## FOREIGN PATENT DOCUMENTS

Exmr Initial	Document Number	Date	Country	Class	Sub Class	Translation YES   NO
JSC	0 708 372 A1	4/1996	EP			
	0 823 327 A2	2/1998	EP			
	0 864 420 A1	9/1998	EP			
	0 908 305 A1	4/1999	EP			
	0 908 307 A2	4/1999	EP			
	0 908 779 A1	4/1999	EP			
	0 908 784 A1	4/1999	EP			
	0 940 266 A1	9/1999	EP			
	0 950 518 A1	10/1999	EP			
	0 960 728 A1	12/1999	EP			
	1 023 994 A1	8/2000	EP			
	1 245 924	2/1972	GB			
	2001042509	2/2001	JP (English Abstract provided)			
	2001042510	2/2001	JP (English Abstract provided)			

## OTHER DOCUMENTS

(Including Author, Title, Date, Pertinent Pages, Etc.)

		"Diazonaphthoquinone-based Resists," R. Dammel, pp. 104-106, SPIE, 1993
		"Positive Resists Based on Diazonaphthoquinones," in <u>Photoreactive Polymers</u> , A. Reiser, pp. 179-225, Wiley, 1989

Examiner	J. Ch	Date Considered	9/2004
----------	-------	-----------------	--------

Examiner: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.